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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09/233,377
Filing Date January 18, 1999
Inventor Gurtej S. Sandhu et al.
Assignee Micron Technology, Inc.
Group Art Unit 2813
Examiner T. Pham
Attorney's Docket No. MI22-1114
Title: Method of Forming a Refractory Metal Silicide (as Amended)

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Reference - - See attached Form PTO-1449

In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, your attention is directed to the United States patent listed on the attached Form PTO-1449. No admission is made regarding whether the submitted reference is prior art.

Citation of this reference is respectfully requested.

Respectfully submitted,

Date: Feb. 19, 2002

Frederick M. Fliegel, Ph.D.
Reg. No. 36,138
Wells St. John P.S.
601 W. First Avenue, Suite 1300
Spokane, WA 99201-3828
(509) 624-4276

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